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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/881,825	06/18/2001	Noriyuki Miyamoto	209822US2S	7751

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[REDACTED] EXAMINER

DONG, DALEI

[REDACTED] ART UNIT

[REDACTED] PAPER NUMBER

2875

DATE MAILED: 11/20/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	09/881,825	MIYAMOTO ET AL.	
	Examiner Dalei Dong	Art Unit 2875	
<i>-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --</i>			
Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.			
<ul style="list-style-type: none"> - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). 			
Status			
1) <input checked="" type="checkbox"/> Responsive to communication(s) filed on <u>18 June 2001</u> .			
2a) <input type="checkbox"/> This action is FINAL.		2b) <input checked="" type="checkbox"/> This action is non-final.	
3) <input type="checkbox"/> Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.			
Disposition of Claims			
4) <input checked="" type="checkbox"/> Claim(s) <u>1-5</u> is/are pending in the application.			
4a) Of the above claim(s) _____ is/are withdrawn from consideration.			
5) <input type="checkbox"/> Claim(s) _____ is/are allowed.			
6) <input checked="" type="checkbox"/> Claim(s) <u>1-5</u> is/are rejected.			
7) <input type="checkbox"/> Claim(s) _____ is/are objected to.			
8) <input type="checkbox"/> Claim(s) _____ are subject to restriction and/or election requirement.			
Application Papers			
9) <input checked="" type="checkbox"/> The specification is objected to by the Examiner.			
10) <input checked="" type="checkbox"/> The drawing(s) filed on <u>18 June 2001</u> is/are: a) <input checked="" type="checkbox"/> accepted or b) <input type="checkbox"/> objected to by the Examiner.			
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).			
11) <input type="checkbox"/> The proposed drawing correction filed on _____ is: a) <input type="checkbox"/> approved b) <input type="checkbox"/> disapproved by the Examiner.			
If approved, corrected drawings are required in reply to this Office action.			
12) <input type="checkbox"/> The oath or declaration is objected to by the Examiner.			
Priority under 35 U.S.C. §§ 119 and 120			
13) <input checked="" type="checkbox"/> Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).			
a) <input type="checkbox"/> All b) <input type="checkbox"/> Some * c) <input type="checkbox"/> None of:			
1. <input checked="" type="checkbox"/> Certified copies of the priority documents have been received.			
2. <input checked="" type="checkbox"/> Certified copies of the priority documents have been received in Application No. <u>09/881,825</u> .			
3. <input type="checkbox"/> Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).			
* See the attached detailed Office action for a list of the certified copies not received.			
14) <input type="checkbox"/> Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).			
a) <input type="checkbox"/> The translation of the foreign language provisional application has been received.			
15) <input type="checkbox"/> Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.			
Attachment(s)			
1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)		4) <input type="checkbox"/> Interview Summary (PTO-413) Paper No(s). _____	
2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)		5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)	
3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____		6) <input type="checkbox"/> Other: _____	

DETAILED ACTION

Specification

1. Applicant is reminded of the proper language and format for an abstract of the disclosure.

The abstract should be in narrative form and generally limited to a single paragraph on a separate sheet within the range of 50 to 150 words. It is important that the abstract not exceed 150 words in length since the space provided for the abstract on the computer tape used by the printer is limited. The form and legal phraseology often used in patent claims, such as "means" and "said," should be avoided. The abstract should describe the disclosure sufficiently to assist readers in deciding whether there is a need for consulting the full patent text for details.

The language should be clear and concise and should not repeat information given in the title. It should avoid using phrases which can be implied, such as, "The disclosure concerns," "The disclosure defined by this invention," "The disclosure describes," etc.

2. The disclosure is objected to because of the following informalities:

On page 2, line 13 the word "intensity" should be revise to intensify.

On page 15, line 5 the dimension "4/D" should be revise to D/4.

Appropriate correction is required.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

4. Claims 1-5 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent No. 5,162,695 to Shimona.

Regarding to claims 1 and 5, Shimona discloses in Figures 4 and 5, "electron gun assembly 100 disposed in neck 5 comprises cathodes K, first grid G1, second grid G2, third grid G3, fourth grid G4, fifth grid G5, sixth grid G6, seventh grid G7, insulating support member BG for supporting these grids and valve spacer 112. Electron gun 100 is fixed to stem pins 113 of the rear portion of the neck. Cathodes K each have a heater inside and generate three electron beams BR, BG and BB. The first and second grids G1 and G2 each have three relatively small beam-passing apertures corresponding to three cathodes K. These apertures serve to control and accelerate the electron beams generated by cathodes K. These cathodes K, the first and the second grids G1 and G2 constitute the so-called electron beam generating section GE. The third, fourth and fifth grids G3, G4 and G5 each have three relatively large beam-passing apertures corresponding to three cathodes K.

As shown in FIG. 4, four electrodes 20, 21, 22 and 23, extending perpendicularly to the direction of in-line arrangement (X-Z plane), are arranged in the in-line arrangement direction to hold therein three beam-passing apertures 52R, 52G and 52B on that side of the fifth grid G5 which faces the sixth grid G6. Referring to FIG. 5, the sixth grid G6 has two electrodes 24 and 25 extending in parallel with the in-line arrangement direction and has two electrodes 24 and 25 fixed on the side facing the fifth grid G5. Three beam-passing apertures 61R, 61G and 61B are formed in the side of the sixth grid G6 between the electrodes 24 and 25. FIG. 4 shows that the

four electrodes 20, 21, 22 and 23 fixed on the fifth grid G5 are arranged between electrodes 24 and 25 of the sixth grid G6. When voltage is applied across the fifth grid G5 and the sixth grid G6, quadrupoles are formed between the four electrode plates of fifth grid G5 and the two electrode plates of the sixth grid G6.

The sixth grid G6, which is a generally cup-shaped electrode, has formed on the side facing the fifth grid G5 three beam-passing apertures 61R, 61G and 61B generally identical in size with beam-passing apertures 52R, 52G and 52B of the fifth grid G5. The sixth grid G6 has formed on the side facing the seventh grid G7 a single large round aperture 62 to pass the beams therethrough. In this cup-shaped electrode and at the mid-point in the longitudinal direction thereof, there is electrode 60 having a racetrack-like beam-passing aperture 63 with its major axis in the in-line arrangement direction (X direction) as shown in FIG. 6A. This beam-passing aperture 63 is placed at a specified distance "a" from the end of the side of the sixth grid G6 closer to the seventh grid G7. The distance "a" is smaller than the diameter D6 of large round aperture 62.

The seventh grid G7 is generally a cylindrical electrode, and a part of the cylindrical sixth grid G6 is received therein. A large-diameter cylindrical lens is formed between the seventh grid G7 and round aperture 62 of sixth grid G6. Electrode 70 is provided in the cylindrical electrode of the seventh grid G7, placed at a specified distance "b" from the end of the sixth grid G6 towards the screen. Electrode 70 has therein a racetrack-like beam-passing aperture 73 with its minor axis in the in-line arrangement direction (X direction) as shown in FIG. 6B. The relation of the specified distance "b" to the cylinder diameter D7 of the seventh grid G7 is $b < D7$. In this embodiment, the

distances "a" and "b" are selected to satisfy an inequality, $a>b$ " (column 4, line 56-68 to column 5, line 1-52).

Shimona further discloses "as the voltages are applied to the electrodes as described, the electron beams produced by the cathodes K, in response to modulation signals, form crossover CO as shown in FIG. 8 due to the cathodes K, the first grid G1 and the second grid G2. Therefore, the electron beam diverged at this crossover CO is slightly focused by the prefocus lens PL formed by the second grid G2 and the third grid G3. Therefore, the electron beam is made to form a virtual crossover point VCO by the prefocus lens PL, and the lens QEL so that the electron beam is seen as if it is produced at the crossover VCO corresponding to the image point of the crossover CO, diverged and incident on the third grid G3. The beams BR, BG and BB incident on third grid G3 are focused towards screen 2 and are also converged towards a point on screen 2 by the main electron lens ML1 formed by the third grid G3 to the seventh grid G7. Thus, the side beams are deflected by the convergence as described towards the center beam and to a common convergence point near the screen" (column 6, line 16-35).

Regarding to claims 2-4, Shimona discloses in Figure 11-12 "two electrode plates 53 and 54, which are located above and below the three beam-passing apertures 52R, 52G and 52B, are fixed to the end of the fifth grid G5. Likewise, two electrode plates 511 and 512, located above and below three beam-passing apertures 511R, 511G and 511B are fixed to the side of the additional grid G51 facing the fifth grid. Four electrode plates 513, 514, 515 and 516 are arranged in the upright position on the side of the

additional grid G51 which faces the sixth grid G6. Likewise, four electrode plates 612, 613, 614 and 615 are arranged in the upright position to hold three beam-passing apertures 61R, 61G and 61B therebetween on the side of the sixth grid G6 which faces the grid G51. In the sixth and seventh grids G6 and G7, noncircular beam-passing aperture 63 is provided to form a large-diameter cylindrical lens just as in the above-described embodiment.

When the fifth grid G5, the additional grid G51, the sixth grid G6 and the seventh formed, between the opposing electrode plates of the fifth grid G5 and the additional grid G51, which does not have focusing power in the horizontal direction but has a focusing power only in the vertical direction. And, a parallel plate lens FLV is formed, between the opposing electrode plates, the additional grid G51, and the sixth grid G6, which does not have focusing power in the vertical direction but has a focusing power only in the horizontal direction.

With the arrangement described, the electron beams are strongly focused by the lens FLV and the lens FLH. The electron beams from the beam generating section GE are focused strongly in the horizontal direction to be generally parallel and focused slightly in the vertical direction. The beams, still diverged, are incident on the common large-diameter asymmetric lens LEL and the three beams are focused and converged on the screen by the large-diameter lens as in the above-described embodiment" (column 9, line 52-68 to column 10, line 1-22).

Art Unit: 2875

Conclusion

5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

The following patents are cited to further show the states of the art for the cathode-ray tube.

U.S. Patent No. 4,086,513 to Evans, Jr.

U.S. Patent No. 4,366,414 to Hatayama.

U.S. Patent No. 4,772,827 to Osakabe.

U.S. Patent No. 5,061,811 to Suzuki.

U.S. Patent No. 5,113,112 to Shmoma.

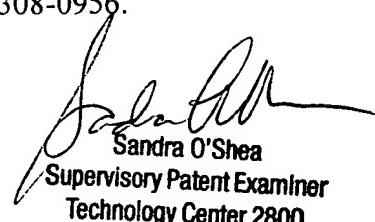
U.S. Patent No. 5,814,929 to Jo.

U.S. Patent No. 5,990,637 to Cho.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dalei Dong whose telephone number is (703)308-2870. The examiner can normally be reached on 8 A.M. to 5 P.M..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sandra O'Shea can be reached on (703)305-4939. The fax phone numbers for the organization where this application or proceeding is assigned are (703)308-7722 for regular communications and (703)308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0956.



Sandra O'Shea
Supervisory Patent Examiner
Technology Center 2800

D.D.

November 13, 2002